Attorney Docket Number: 04329.2718

AMENDMENTS TO THE CLAIMS:

Please amend claims 1, 6, 8, 12, 90, and 94, as indicated below. This listing of claims

will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

1. (Currently Amended) A heating apparatus for a coating film comprising:

a chamber having an inner space;

a heating plate for heating configured to heat a substrate to be processed, said heating

plate having a support surface that supports the substrate to be processed with a coating film in

said chamber;

a partition member arranged in said chamber so as to face the support surface, said

partition member partitioning the inner space into first and second spaces and having a plurality

of pores allowing the first and second spaces to connect with each other, the support surface

being set in the first space, and the second space connected with an outside of said chamber

through a first opening and a second opening formed in sides of said chamber; and

an air stream formation mechanism forming an air stream in the second space in order to

discharge a substance evaporated from the coating film.

2. (Original) The apparatus according to claim 1, wherein said partition member is

detachable from said heating apparatus.

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3. (Original) The apparatus according to claim 1, wherein said partition member is

formed from a material selected from the group consisting of a porous ceramic and a corrosion-

resistant metal.

4. (Original) The apparatus according to claim 1, wherein said partition member has a

pore diameter falling within a range of 2 µm to 100 µm.

5. (Previously Presented) The apparatus according to claim 1, wherein said air stream

formation mechanism and at least condition selected from the group consisting of a pore

diameter and porosity of said partition member are adjusted so as to discharge the evaporated

substance into the second space via the plurality of pores of said partition member.

6. (Currently Amended) A heating apparatus for a coating film comprising:

a chamber having an inner space;

a heating plate for heating configured to heat a substrate to be processed, said heating

plate having a support surface that supports the substrate to be processed with a coating film in

said chamber; and

an adsorption plate arranged in said chamber so as to face the support surface, a surface

of the adsorption plate which faces the substrate to be processed adsorbing a substance

evaporated from the coating film.

7. (Original) The apparatus according to claim 6, wherein said adsorption plate is

formed from a material selected from the group consisting of an oxide, a nitride, a material with

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an oxide surface facing the substrate to be processed, and a material with a nitride surface facing

the substrate to be processed.

8. (Currently Amended) The apparatus according to claim 6, wherein said adsorption

plate comprises a temperature control function for controlling configured to control a

temperature of said adsorption plate.

9. (Original) The apparatus according to claim 8, wherein said temperature control

function sets the temperature of said adsorption plate to be higher than a temperature of said

substrate to be processed.

10. (Original) The apparatus according to claim 8, wherein said temperature control

function sets the temperature of said adsorption plate to be lower than a temperature of said

substrate to be processed.

11. (Original) The apparatus according to claim 8, wherein said adsorption plate is

formed from a material selected from the group consisting of an oxide, a nitride, a material with

an oxide surface facing said substrate to be processed, and a material with a nitride surface

facing said substrate to be processed.

12. (Currently Amended) The apparatus according to claim 6, wherein

said adsorption plate is formed from a metal member, and

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said apparatus further comprises a voltage generator for generating configured to

generate an electric field between said heating plate and said metal member.

13. (Original) The apparatus according to claim 12, wherein said metal member receives

a voltage lower than said heating plate from said voltage generator, and adsorbs said evaporated

substance.

14. (Original) The apparatus according to claim 12, wherein said metal member receives

a voltage higher than said heating plate from said voltage generator, and suppresses generation of

said evaporated substance.

15-85. (Cancelled)

86. (Previously Presented) The apparatus according to claim 1, wherein the second

space is positioned above the first space.

87. (Previously Presented) The apparatus according to claim 1, wherein the air stream

contains the substance.

88. (Previously Presented) The apparatus according to claim 1, wherein the first opening

is formed in a first side surface of the chamber and the second opening is formed in a second side

surface of the chamber opposite the first side surface.

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89. (Previously Presented) The apparatus according to claim 6, wherein the adsorption

plate is positioned above the support surface.

90. (Currently Amended) A heating apparatus for a coating film comprising:

a chamber having an inner space;

a heating plate for heating configured to heat a substrate to be processed, said heating

plate having a support surface that supports the substrate to be processed with a coating film in

said chamber; and

an adsorption plate arranged in said chamber so as to face the support surface, said

adsorption plate adsorbing a substance evaporated from the coating film, and said adsorption

plate including a temperature control function for controlling a temperature of said adsorption

plate.

91. (Previously Presented) The apparatus according to claim 90, wherein said

temperature control function sets the temperature of said adsorption plate to be higher than a

temperature of said substrate to be processed.

92. (Previously Presented) The apparatus according to claim 90, wherein said

temperature control function sets the temperature of said adsorption plate to be lower than a

temperature of said substrate to be processed.

93. (Previously Presented) The apparatus according to claim 90, wherein said adsorption

plate is formed from a material selected from the group consisting of an oxide, a nitride, a

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material with an oxide surface facing said substrate to be processed, and a material with a nitride

surface facing said substrate to be processed.

94. (Currently Amended) A heating apparatus for a coating film comprising:

a chamber having an inner space;

a heating plate for heating configured to heat a substrate to be processed, said heating

plate having a support surface that supports the substrate to be processed with a coating film in

said chamber;

an adsorption plate formed from a metal member and arranged in said chamber so as to

face the support surface, said adsorption plate adsorbing a substance evaporated from the coating

film; and

a voltage generator for generating an electric field between said heating plate and said

metal member.

95. (Previously Presented) The apparatus according to claim 94, wherein said metal

member receives a voltage lower than said heating plate from said voltage generator, and adsorbs

said evaporated substance.

96. (Previously Presented) The apparatus according to claim 94, wherein said metal

member receives a voltage higher than said heating plate from said voltage generator, and

suppresses generation of said evaporated substance.

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